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PRELIMINARY AMENDMENT
ACCOMPANYING THE FILING OF AN APPLICATION

APPLICANT(s): Shinichiro Noudo et al.
ATTORNEY DOCKET NO.: 075834.00434
INTERNATIONAL APPLICATION NO.: PCT/JP03/09926
INTERNATIONAL FILING DATE: August 5, 2003
INVENTION: COMPLEMENTARY DIVISION MASK HAVING
ALIGNMENT MARK, METHOD FOR FORMING
ALIGNMENT MARK OF THE COMPLEMENTARY
DIVISION MASK, SEMICONDUCTOR DEVICE
MANUFACTURED BY USING THE
COMPLEMENTARY DIVISION MASK, AND ITS
MANUFACTURING METHOD

CUSTOMER NO.: 33448

Mail Stop PCT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Please amend the application as follows:

Amendment to the Title begins on page 2.

Amendment to the Specification begins on page 3.

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AMENDMENT TO THE TITLE OF THE INVENTION:

Please amend the title of the invention to:

COMPLEMENTARY ~~DIVISION~~ DIVIDED MASK HAVING
ALIGNMENT ~~MARK~~ MARKS, METHOD FOR FORMING
ALIGNMENT ~~MARK OF THE~~ MARKS IN COMPLEMENTARY
~~DIVISION~~ DIVIDED MASK, SEMICONDUCTOR DEVICE
MANUFACTURED ~~[[BY]]~~ USING ~~[[THE]]~~ COMPLEMENTARY
~~DIVISION~~ DIVIDED MASK, AND ~~ITS MANUFACTURING METHOD~~
FOR MANUFACTURING THE SAME